

L Number	Hits	Search Text	DB	Time stamp
1	207627	(nh3 or "nh.sub3." or "nh.sub.3." or ammonia or hydrogen or h2 or "h.sub.2" or "h.sub2.") with (o2 or oxygen or "o.sub2." or "o.sub.2" or air or n20 or "n.sub2. o" or "n.sub.2 o" or (nitrogen adj oxide))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 13:00
2	3870	((nh3 or "nh.sub3." or "nh.sub.3." or ammonia or hydrogen or h2 or "h.sub.2" or "h.sub2.") with (o2 or oxygen or "o.sub2." or "o.sub.2" or air or n20 or "n.sub2. o" or "n.sub.2 o" or (nitrogen adj oxide))) with clean\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 13:00
3	5	(( (nh3 or "nh.sub3." or "nh.sub.3." or ammonia or hydrogen or h2 or "h.sub.2" or "h.sub2.") with (o2 or oxygen or "o.sub2." or "o.sub.2" or air or n20 or "n.sub2. o" or "n.sub.2 o" or (nitrogen adj oxide))) with clean\$4) with ((chamber or apparatus) near1 surface)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 13:01
-	3327	216/67.ccls. or 438/905.ccls. or 134/22.1.ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:14
-	1086	(216/67.ccls. or 438/905.ccls. or 134/22.1.ccls.) and (nh3 or "nh.sub3." or "nh.sub.3." or ammonia or hydrogen or h2 or "h.sub.2" or "h.sub2.")	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:15
-	236	(216/67.ccls. or 438/905.ccls. or 134/22.1.ccls.) and (nh3 or "nh.sub3." or "nh.sub.3." or ammonia or hydrogen or h2 or "h.sub.2" or "h.sub2.").ab.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 12:25
-	143	((216/67.ccls. or 438/905.ccls. or 134/22.1.ccls.) and (nh3 or "nh.sub3." or "nh.sub.3." or ammonia or hydrogen or h2 or "h.sub.2" or "h.sub2.").ab.) and (o2 or oxygen or "o.sub2." or "o.sub.2." or air or n2o "n.sub2. o" or "n.sub.2 o" or (nitrogen adj oxide))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 12:25
-	62	((216/67.ccls. or 438/905.ccls. or 134/22.1.ccls.) and (nh3 or "nh.sub3." or "nh.sub.3." or ammonia or hydrogen or h2 or "h.sub.2" or "h.sub2.").ab.) and (o2 or oxygen or "o.sub2." or "o.sub.2." or air or n2o "n.sub2. o" or "n.sub.2 o" or (nitrogen adj oxide)).ab.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:29
-	334	deposition adj residue	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 12:01
-	129	(deposition adj residue) with clean\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:29
-	23	((deposition adj residue) with clean\$4) with fluorine	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:44
-	2	("5873781").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:38

-	2	("5973781").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:38
-	0	("frankel").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:38
-	5323	frankel	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:38
-	1076	frankel.in.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:39
-	5	((216/67.ccls. or 438/905.ccls. or 134/22.1.ccls.) and (nh3 or "nh.sub3." or "nh.sub.3." or ammonia or hydrogen or h2 or "h.sub.2" or "h.sub2.")) and (((deposition adj residue) with clean\$4) with fluorine)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 11:44
-	8006	deposit\$4 near1 (residu\$4 or contamina\$4)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 12:02
-	79	(deposit\$4 near1 (residu\$4 or contamina\$4)) with ((chamber or apparatus) near1 surface)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 12:10
-	11	(deposit\$4 near1 (residu\$4 or contamina\$4)) with ((chamber or apparatus) near1 surface).ab.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 12:14
-	611256	(nh3 or "nh.sub3." or "nh.sub.3." or ammonia or hydrogen or h2 or "h.sub.2" or "h.sub2.").ab.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 12:58
-	1758641	(o2 or oxygen or "o.sub2." or "o.sub.2." or air or n2o "n.sub2. o" or "n.sub.2 o" or (nitrogen adj oxide)).ab.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 12:25
-	96906	((nh3 or "nh.sub3." or "nh.sub.3." or ammonia or hydrogen or h2 or "h.sub.2" or "h.sub2.").ab.) and ((o2 or oxygen or "o.sub2." or "o.sub.2." or air or n2o "n.sub2. o" or "n.sub.2 o" or (nitrogen adj oxide)).ab.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 12:26
-	1	((deposit\$4 near1 (residu\$4 or contamina\$4)) with ((chamber or apparatus) near1 surface).ab.) and ((o2 or oxygen or "o.sub2." or "o.sub.2." or air or n2o "n.sub2. o" or "n.sub.2 o" or (nitrogen adj oxide)).ab.)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/17 12:26